Tracking Simulation Update

Jinlong Zhang (SBU) August 9, 2019 SoLID Collaboration Meeting

Outline

- Tracking framework: digitization and tracking (Rich, Ole, Weizhi, ...)
- Alternative to APV
 - Readout with SAMPA (SIDIS)
 - Readout with VMM (PVDIS)
- Summary

GEM position





SIDIS / J/psi

PVDIS

Tracking framework



- 1. From MC events, simulate energy to charge using Cauchy-Lorentz mode
- 2. At strip level, simulate charge to ADC based on shaping functions (pulse shape)
- 3. Accumulate ADC contributed by signal hit and background hits in a given time window (determined by the pulse length)
- 4. From accumulated ADC for each strip:
 - APV and SAMPA: one sample (at peak position) or multi-sample (leading edge) for shape analysis
 - VMM: peak seeking -> one sample
- 5. Smear ADC with pedestal noise (Gaussian)
- 6. Clustering and tracking

Tracking Evaluation

- Efficiency:

- event level, fraction of events with good track(s) reconstructed
- Single track signal event
- Accuracy:
 - track level, fraction of reconstructed tracks matching to MC tracks
 - Distance between hit on track and MC hit within 3 pitches
- Resolution:
 - how well kinematic variables reconstructed: momentum, theta, phi, vertex Z

APV, SAMPA, and VMM

| | Shaping time (ns) | Sampling period (ns) | ADC bits | |
|----------|--------------------------|----------------------|----------|--|
| APV25 | 50 | 25 | 10 | |
| SAMPA160 | 160 | 50 | 10 | |
| SAMPA80 | 80 | 50 | 10 | |
| VMM3 | 25, 50 , 100, 200 | peak seeking | 6 | |

Slower shaping -> Larger time window -> more background hits -> lower tracking efficiency/accuracy

Longer sampling period -> lower pulse shape resolution

Lower ADC bits -> lower ADC resolution

SAMPA



- Two versions: 160 ns (used by ALICE TPC) and 80 ns shaping time
- 50 ns sampling step (25 for APV)
- One sample: 5th for 160; 3rd for 80

SAMPA for SIDIS



- SAMPA 160: ~10% worse for both efficiency and accuracy than APV
- SAMPA 80: better than SAMPA 160 as expected, ~3% worse than APV25 for FA tracking efficiency.

VMM

Preliminary

- "Digital" output: instead of sampling the pulse shape, VMM seeks for pulse peak on the fly; only one "sample" at peak
- Before trigger arrives, VMM keep self-resetting, non-triggered hits (bkgd) and pile-up pulse contribution suppressed significantly
- Low resolution ADC (6-bit)



- Assuming perfect trigger timing
- Background contribution only for those come in 0 - 50 ns (peaking time)

PVDIS Occupancy



- High occupancy is one of main issues impact the tracking efficiency and accuracy
- Without background, two readout modes have similar occupancy
- VMM3 have ~40% lower occupancy than APV25 (3 sample, check pulse shape) with 100% background

VMM



- APV: ADC ~ 200, ped noise sigma~15, ADC min cuts > 95 (didn't tune from Weizhi's setup).
- VMM: ADC ~40, ped noise sigma ~5, ADC min cuts > 16 (tuned to APV to have similar 0% background efficiency)
- Efficiency sensitivity to background ratio seminar for APV and VMM
- Accuracy decreases LESS for VMM (low occupancy) than APV

Summary

- SAMPA160 gives lower efficiency and lower accuracy, both at ~10% level than APV
- SAMPA 80 better than SAMPA160, but slightly worse than APV
- VMM, preliminary studies, using narrow time window for background hits, accuracy improved significantly.

Thanks to Nilanga, Weizhi, and Alex for their inputs.

SAMPA Resolution

| | Forward angle | | | L | Large angle | | |
|------------|---------------|---------|---------|-------|-------------|---------|--|
| | APV | SAMPA80 | SAMPA16 | APV | SAMPA80 | SAMPA16 | |
| Momentum | 1.410 | 1.417 | 1.442 | 1.098 | 1.098 | 1.154 | |
| Theta | 0.995 | 0.998 | 1.066 | 1.054 | 1.053 | 1.068 | |
| Phi (mrad) | 4.147 | 4.166 | 4.229 | 2.142 | 2.104 | 2.219 | |
| Vertex Z | 9.076 | 9.100 | 10.281 | 5.481 | 5.477 | 6.064 | |

- Resolutions for SAMPA80 are comparable with APV25, and better than SAMPA160 with about 5%.